

General Pattern



Technology Disclaimer Policy for EOSINT M 270 DMLS Parts

General Pattern is pleased to offer its customers the benefits of direct metal laser sintering via the EOSINT M 270 platform. As with all new technologies and processes, there will be research and development (R&D) risks related to the outcome. This means specifically that certain part data files will build better than others and often it is not possible to predict with reasonable certainty such outcomes.

General Pattern acknowledges that its customers are willing to accept this R&D risk because they hope to realize tangible benefits in the manufacturing process including significant time and cost savings. For its part, **General Pattern agrees to make a good faith effort only**, in operating the EOSINT M 270, to meet the customer's expectations.

The customer acknowledges that it is willing to accept the R&D risk as outlined above and agrees to pay for the work as ordered even if the outcome is unsatisfactory.

The above is agreed to by:

Company: _____

Signature: _____

Print Name: _____

Title: _____

Date: _____